

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

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JUL 14 2006

In re Applicant:
Robert P. Meagley et al.

Serial No.: 10/688,521

Filed: October 17, 2003

For: Reducing Photoresist Line Edge
Roughness Using Chemically-
Assisted Reflow§
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§
§

Art Unit: 1752

Examiner: Amanda C. Walke

Docket: ITL1026US
P16713

Assignee: Intel Corporation

Mail Stop AF
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450REPLY TO FINAL REJECTION

Sir:

In response to the final rejection mailed June 29, 2006, reconsideration is requested in view of the following remarks.

A current listing of the claims is attached. No amendments were made.

*Do not enter
AOW 7/27/06*

Date of Deposit: July 14, 2006
I hereby certify that this document is being facsimile transmitted to the United States Patent and Trademark Office (Fax No. 571-273-8300) on the date indicated above.
<i>Cynthia L. Hayden</i>
Cynthia L. Hayden